



US00D764124S

(12) **United States Design Patent**
Shinozaki

(10) **Patent No.:** **US D764,124 S**
(45) **Date of Patent:** **** Aug. 16, 2016**

(54) **BRUSH FOR CLEANING SEMICONDUCTOR
POLISHING DISK**

(71) Applicant: **EBARA CORPORATION**, Tokyo (JP)

(72) Inventor: **Hiroyuki Shinozaki**, Tokyo (JP)

(73) Assignee: **EBARA CORPORATION**, Tokyo (JP)

(**) Term: **14 Years**

(21) Appl. No.: **29/445,125**

(22) Filed: **Feb. 7, 2013**

(30) **Foreign Application Priority Data**

Aug. 7, 2012 (JP) 2012-018893

(51) **LOC (10) Cl.** **15-05**

(52) **U.S. Cl.**
USPC **D32/25**

(58) **Field of Classification Search**
USPC D4/130, 119, 114, 136, 129, 100, 120,
D4/199; 15/143.1; D30/158; D24/119;
D25/113; D32/25
See application file for complete search history.

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Primary Examiner — John Windmuller

Assistant Examiner — Luqman McNeil

(74) *Attorney, Agent, or Firm* — Pearne & Gordon LLP

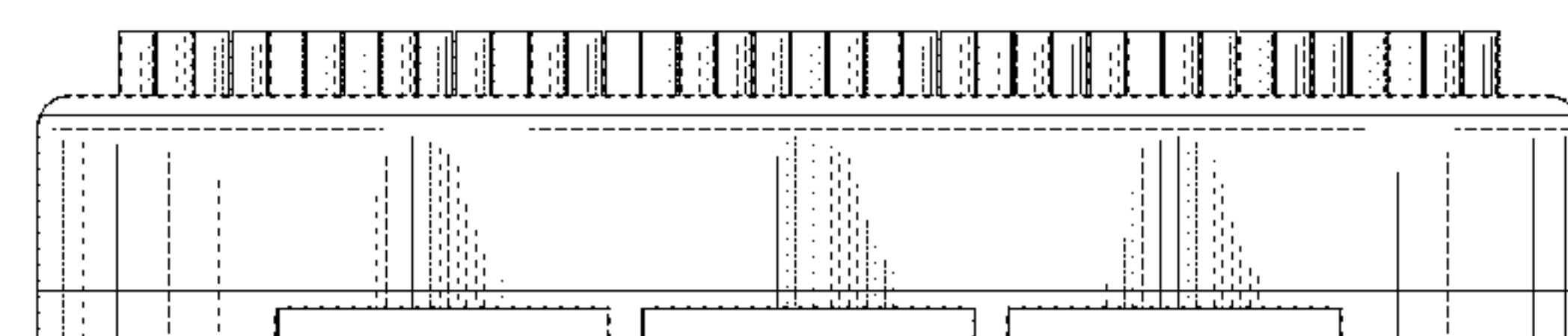
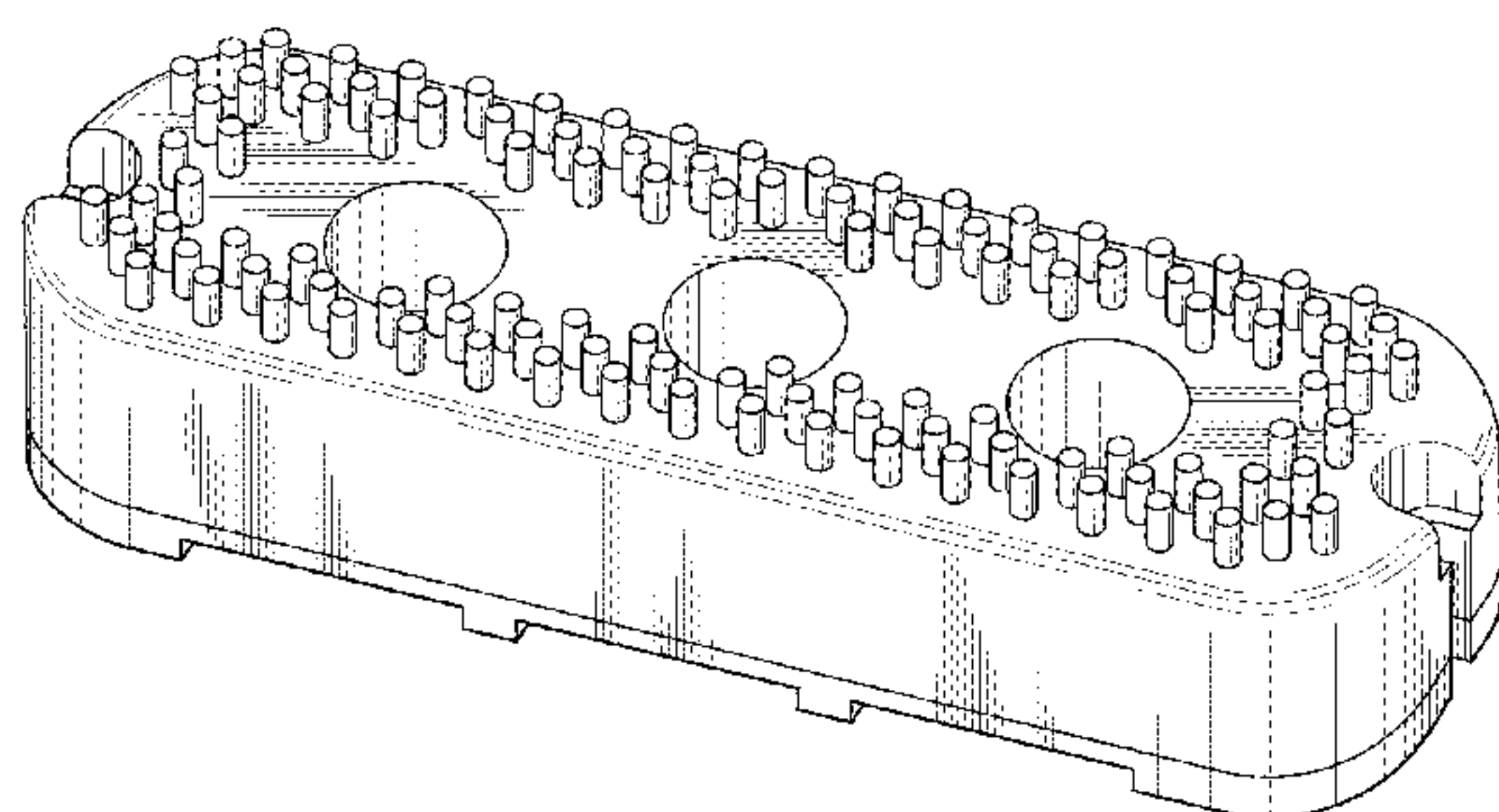
(57) **CLAIM**

The ornamental design for a brush for cleaning semiconductor polishing disk, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a brush for cleaning semiconductor polishing disk showing my new design;
FIG. 2 is a top view thereof;
FIG. 3 is a front elevation view thereof;
FIG. 4 is a bottom plan view thereof;
FIG. 5 is a right side view thereof; and,
FIG. 6 is a reference view showing a usable state thereof.
The broken line showing is included for the purpose of illustrating environment and forms no part of the claimed design.

1 Claim, 6 Drawing Sheets



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FIG. 1

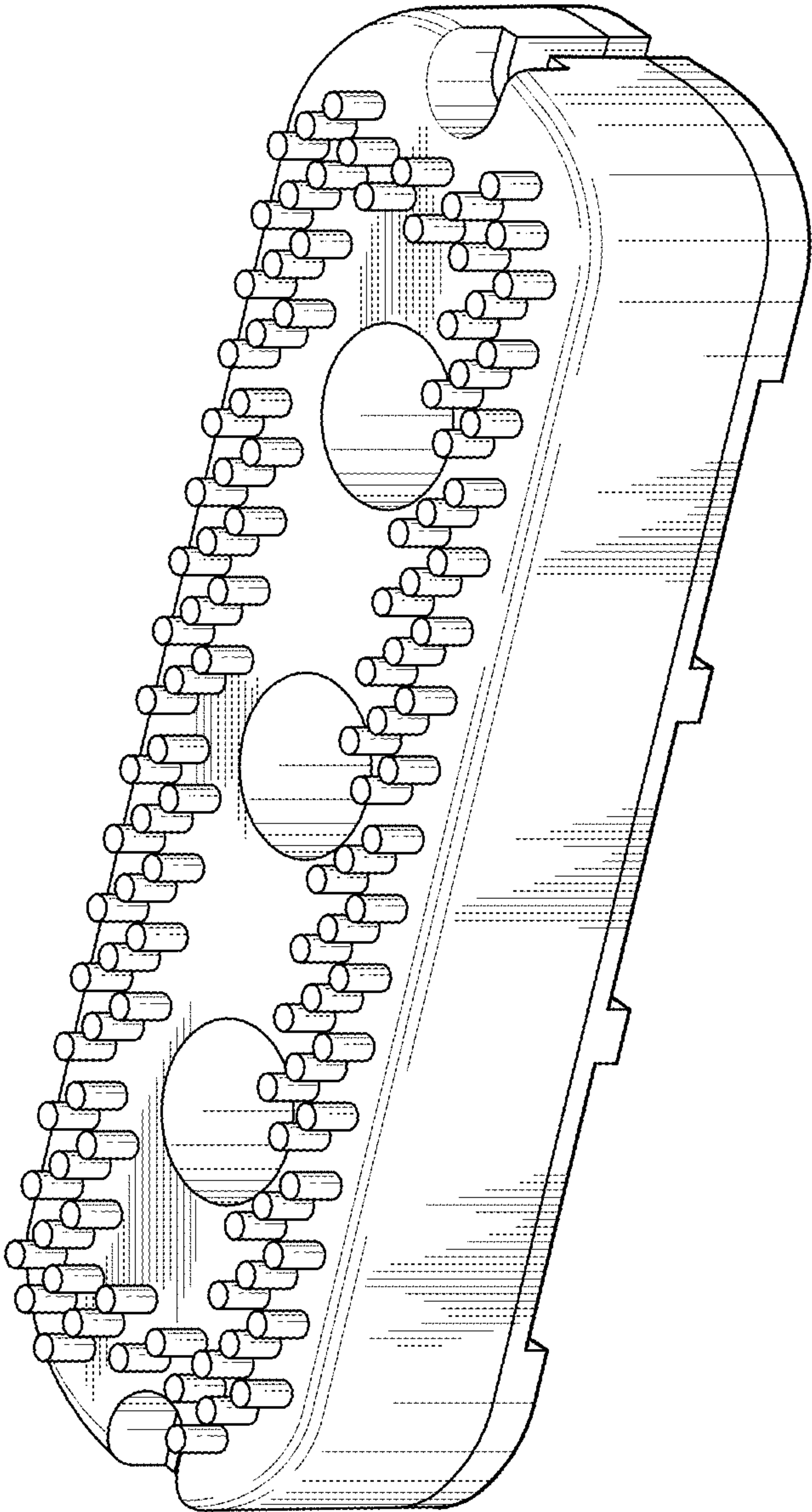


FIG. 2

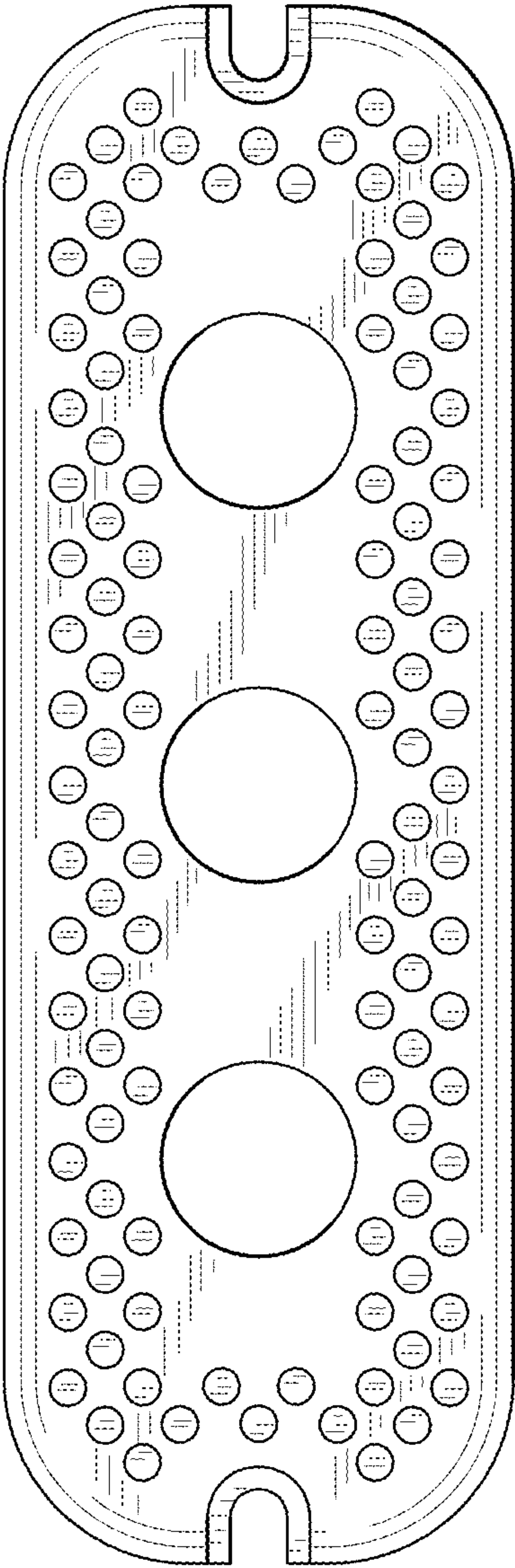


FIG. 3

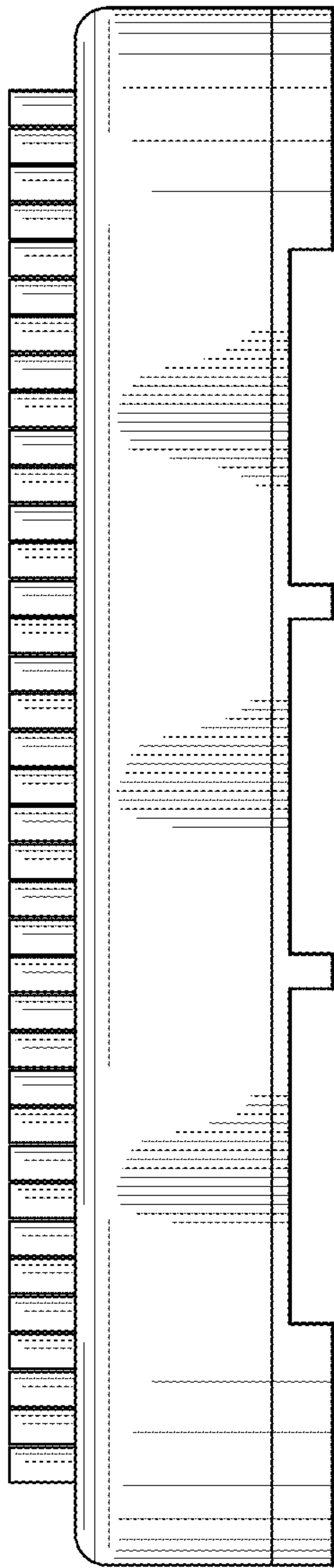


FIG. 4

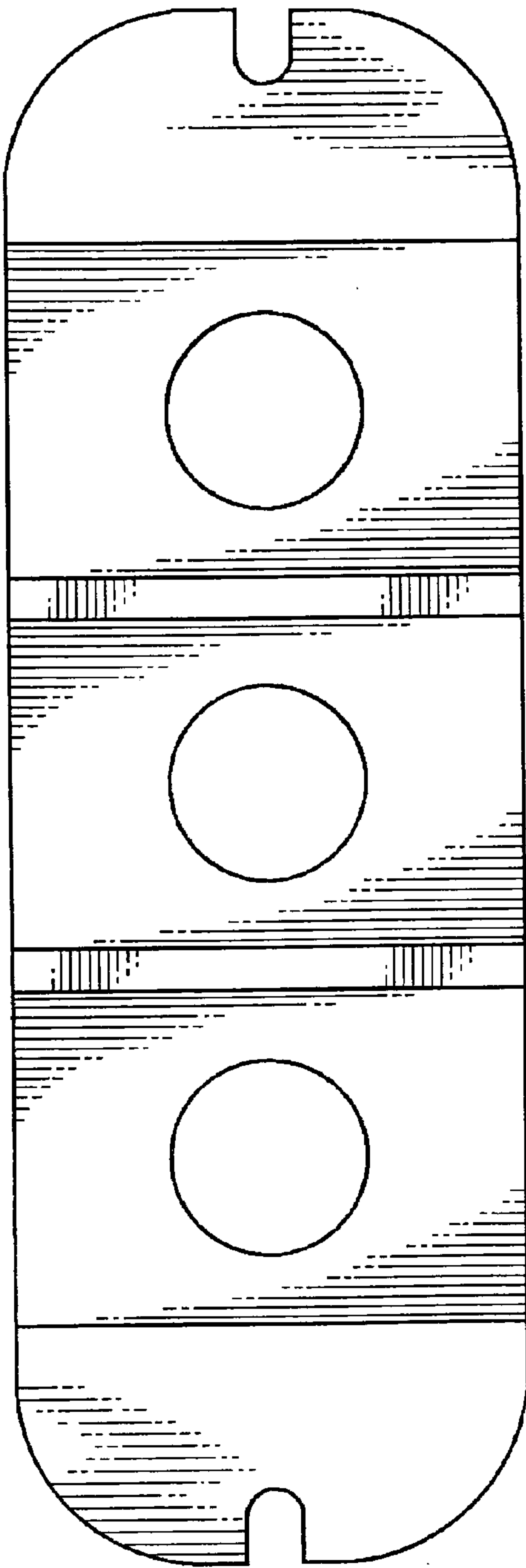


FIG. 5

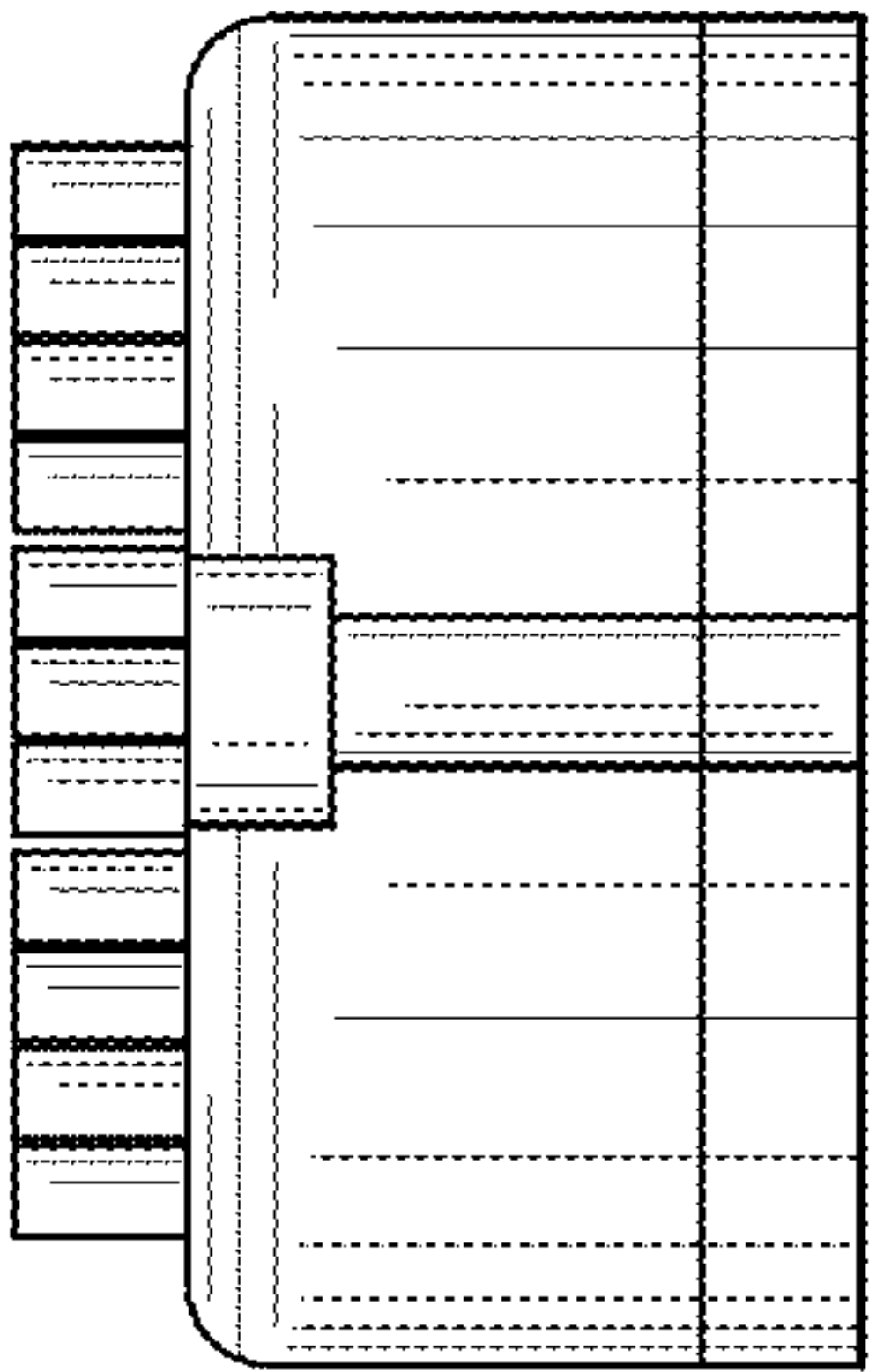


FIG. 6

